

United States Patent and Trademark Office



UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
09/975,358	10/11/2001	Christopher L. Chua	D/99842QD	D/99842QD 3565	
7590 07/27/2004			EXAMINER		
Patent Docume	entation Center	NGUYEN, DAO H			
Xerox Corporati					
Xerox Square 20	Oth Floor	ART UNIT	PAPER NUMBER		
100 Clinton Ave	e. S.	2818			
Rochester, NY 14644			DATE MAILED: 07/27/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Applicatio	n No.	Applicant(s)				
Office Action Summary		09/975,35	09/975,358 CHUA ET AL.					
		Examiner		Art Unit				
		Dao H Ngu	yen	2818	AN			
Period fo	The MAILING DATE of this communication a or Reply	ppears on the	cover sheet with the o	correspondence add	ress			
A SH THE - Exte after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REP MAILING DATE OF THIS COMMUNICATION nsions of time may be available under the provisions of 37 CFR SIX (6) MONTHS from the mailing date of this communication. It period for reply specified above is less than thirty (30) days, a report of the property of the maximum statutory period for reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply within the set or extended period for reply will, by stature to reply will be r	I. 1.136(a). In no eve eply within the statu d will apply and wil ute, cause the appli	nt, however, may a reply be tir tory minimum of thirty (30) day expire SIX (6) MONTHS from cation to become ABANDONE	nely filed s will be considered timely. the mailing date of this con D (35 U.S.C. § 133).	nmunication.			
Status								
1)⊠	Responsive to communication(s) filed on 28	June 2004.						
2a)□	This action is FINAL . 2b)⊠ This action is non-final.							
3)	· · · · · · · · · · · · · · · · · · ·							
,_	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	ion of Claims							
5)⊠ 6)⊠ 7)⊠	 Claim(s) 1 and 12-17 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. Claim(s) 12-15 is/are allowed. Claim(s) 1,16 and 17 is/are rejected. Claim(s) 17 is/are objected to. Claim(s) are subject to restriction and/or election requirement. 							
Applicat	ion Papers							
10)⊠	The specification is objected to by the Exami The drawing(s) filed on <u>11 October 2001</u> is/a Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the	re: a)⊠ acce ne drawing(s) b ection is require	e held in abeyance. Se ed if the drawing(s) is ob	e 37 CFR 1.85(a). ejected to. See 37 CFF	R 1.121(d).			
Priority (under 35 U.S.C. § 119							
12)□ a)	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Buresee the attached detailed Office action for a li	ents have been ents have been riority docume eau (PCT Rule	n received. n received in Applicat nts have been receive e 17.2(a)).	ion No ed in this National S	Stage .			
2) Notice 3) Infor	at (s) ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/0 er No(s)/Mail Date <u>1001</u> .	98)	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal I 6) Other:	ate	·152)			

Application/Control Number: 09/975,358 Page 2

Art Unit: 2818

DETAILED ACTION

1. In response to the communications dated 10/11/2001 through 06/28/2004, claims 1 and 12-17 are active in this application as a result of the cancellation of claims 2-11 in the Preliminary Amendment.

Acknowledges

- 2. Receipt is acknowledged of the following items from the Applicant.
- a. Information Disclosure Statement (IDS) filed on 10/11/2001 and made of record as Paper No. 1001. The references cited on the PTOL 1449 form have been considered.

Applicant is requested to cite any relevant prior art if being aware on form PTO-1449 in accordance with the guidelines set for in M.P.E.P. 609.

b. This patent application is a divisional patent application of U.S. Patent Application Number 09/573,363 filed on May 17, 2000, now paten No. 6,396,677.

Specification

3. The specification is objected to for the following reason:

In the abstract, lines 8-9, the preposition "a" in the phrase "the **a** dielectric layer" should be deleted.

Art Unit: 2818

The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claim Objections

4. The claim is objected to for the following reason: In claim 17, line 26, the period "." at the end of the line should be replaced by a semicolon --;--.

Claim Rejections - 35 USC § 112

- 5. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 6. Claim(s) 16-17 is/are rejected under 35 U.S.C. § 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Regarding claim 16, it is not clearly defined and distinctly pointed out the subject matter which is claimed as the Applicant's invention. What is the preamble and what is the body of the claim? It is an incomplete claim.

Art Unit: 2818

Regarding claim 17, it is not clearly defined and distinctly pointed out the subject matter which is claimed as the Applicant's invention. It is a method of doing what? This claim has no preamble.

Claim Rejection - Double Patenting

7. A rejection based on double patenting of the "same invention" type finds its support in the language of 35 U.S.C. 101 which states that "whoever invents or discovers any new and useful process ... may obtain a patent therefor ..." (Emphasis added). Thus, the term "same invention," in this context, means an invention drawn to identical subject matter. See *Miller v. Eagle Mfg. Co.*, 151 U.S. 186 (1894); *In re Ockert*, 245 F.2d 467, 114 USPQ 330 (CCPA 1957); and *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970).

A statutory type (35 U.S.C. 101) double patenting rejection can be overcome by canceling or amending the conflicting claims so they are no longer coextensive in scope. The filing of a terminal disclaimer <u>cannot</u> overcome a double patenting rejection based upon 35 U.S.C. 101.

8. Claim 1 is rejected under 35 U.S.C. 101 as claiming the same invention as that of claim 1 of prior U.S. Patent No. 6,396,677. This is a double patenting rejection.

Reasons for Allowance

9. Claim(s) 12-15 would be allowed.

The following is an examiner's statement of reason for allowance:

None of the references of record teaches or suggests the claimed method for forming a variable capacitor comprising (in addition to the other limitations in the claim) under-cut etching a portion of the insulating release layer under the second conductive layer to release a free portion of the second layer from the release layer, wherein an anchor portion of the second layer remains fixed to the release layer.

Allowable Subject Matter

Claim(s) 17 would be allowed if rewritten to overcome the rejection under 35 10. USC § 112.

The following is a statement of reason for the indication of allowable subject matter: None of the references of record teaches or suggests the claimed method for forming a variable capacitor comprising (in addition to the other limitations in the claim) under-cut etching a portion of the insulating release layer under the second conductive layer to release a free portion of the capacitor plate layer and the microcoil layer from the release layer, wherein an anchor portion of the second layer remains fixed to the release layer.

Application/Control Number: 09/975,358

Art Unit: 2818

Conclusion

11. A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).

12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dao H. Nguyen whose telephone number is (571)272-1791. The examiner can normally be reached on Monday-Friday, 9:00 AM – 6:00 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571)272-1787. The fax numbers for all communication(s) is 703-872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (571)272-1625.

David Nelms
Supervisory Patent Examiner
Technology Center 2800

Page 6

Dao H. Nguyen Art Unit 2818 July 21, 2004